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Treatment of Point Defects in Nanowire MOSFETs Using the Nonequilibrium Green's Function Formalism

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Outline

□ Introduction

- MOSFETs downscaling: statistical fluctuations of doping impurity positions

□ 3D Quantum simulation of point defects in nanowire transistors

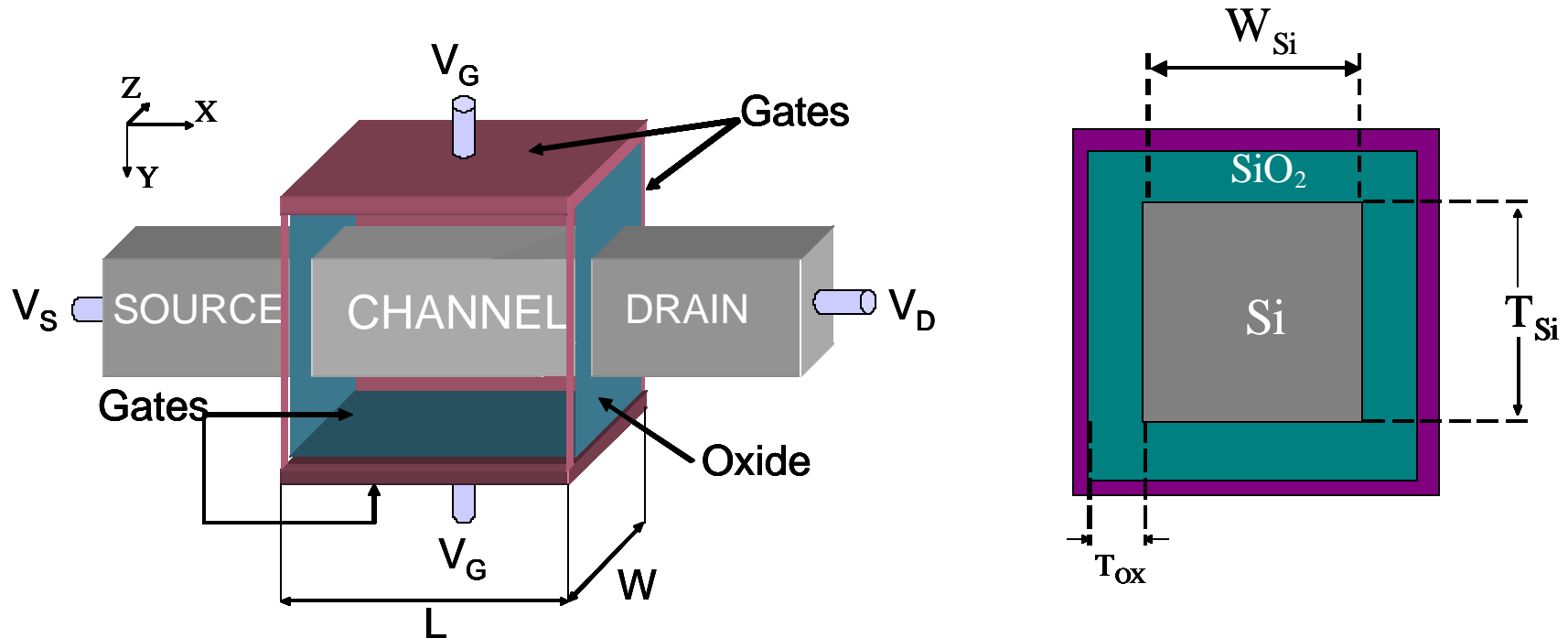
- Nonequilibrium Green Function formalism: Mode-Space approach
- Treatment of point defects

□ Results: influence of the impurity location and type

- Energy subbands
- Transverse modes
- Current characteristics

□ Conclusions and perspectives

Dimensions of nanowire MOSFETs



- ✓ Source and drain region: continuous doping of 10^{20} cm^{-3} .
- ✓ Dimensions: $L=8 \text{ nm}$, $W_{Si}=3 \text{ nm}$, and $T_{Si}=3 \text{ nm}$, $T_{OX}=1 \text{ nm}$.
- ✓ Channel region: discrete doping of 10^{19} cm^{-3} , with 1 impurity on average.

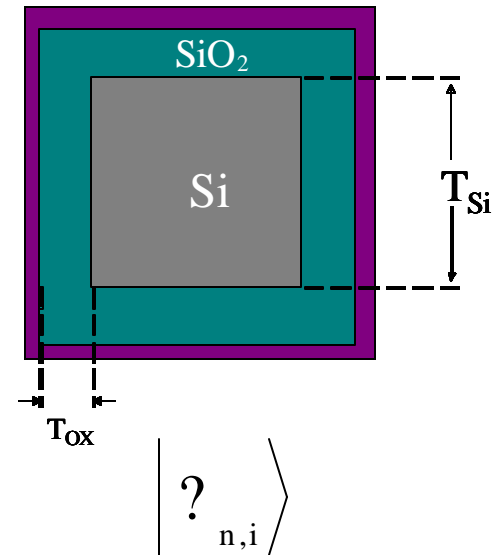
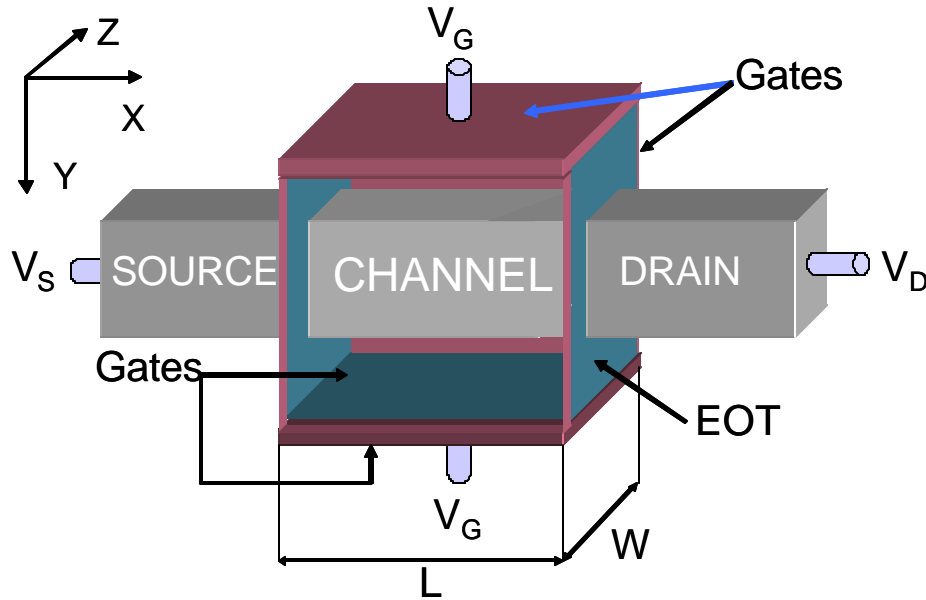
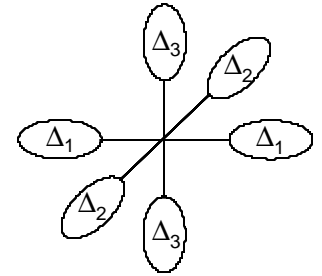
▷ Effect of the impurity type and location.

Nonequilibrium Green's function formalism

Point Defect Treatment

The 3D Mode Space Approach*

- ◆ The 3D Schrödinger = **2D (confinement)** + **1D (transport)**

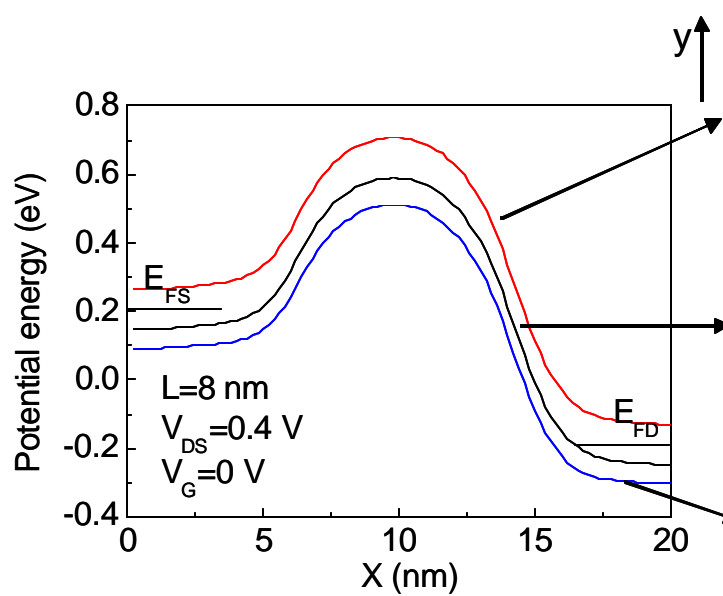


i^{th} eigenstate of the n^{th} atomic plan

- ◆ Hypothesis: $y_{n,i}$ is constant along the transport axis.

The 3D Mode Space Approach

- ◆ Electron distribution along subbands (valley (010)):



- ◆ For each subband i :

3rd $i=3$

$|\ ?_{n,i} \rangle$: Transverse eigenstate

2nd $i=2$

$e_{n,i}$: Transverse eigenvalue

1st $i=1$

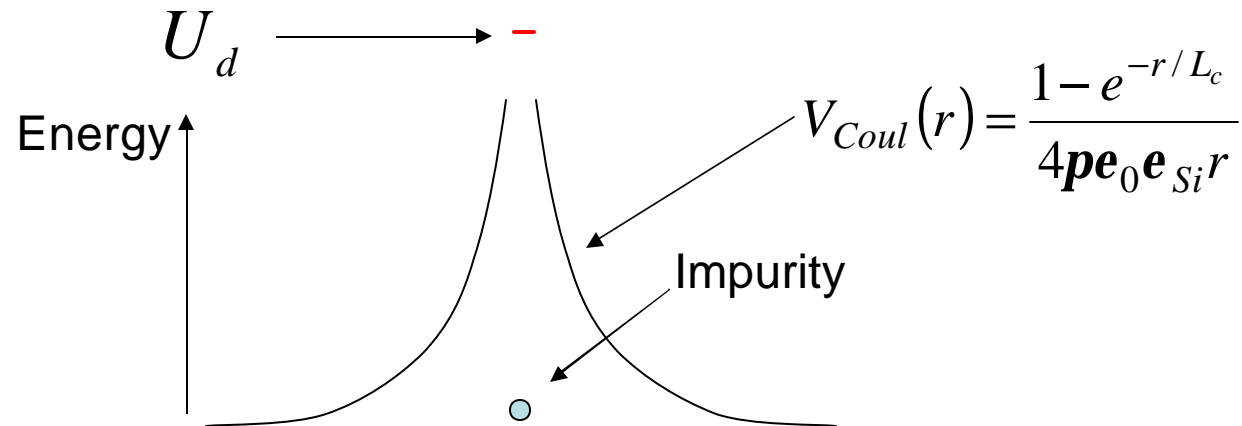
$G_i(e)$: 1D Green function

- ◆ Simplified tight-binding approach: cubic lattice with a_x, a_y, a_z .

- 1 orbital/atom: $|l, m, n\rangle$: position $z=l \times a_z, y=m \times a_y, x=n \times a_x$.

- Interactions between first neighbors.

Point defect description



◆ Point Defect = On-site Potential + Coulomb Tail

Treated as a localized variation
= Chemical structure

⇒ Included in the real space approach
based on the Dyson equation.

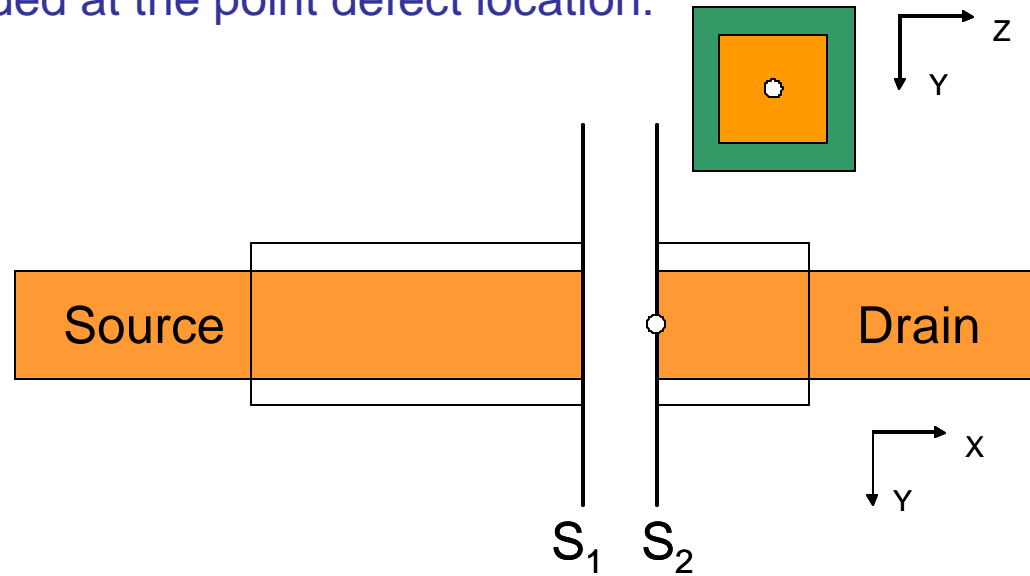
$$[G = (I - G_0 V)^{-1} G_0]$$

Treated as a macroscopic variation

⇒ Included in the self-consistent mode-
space approach without coupling the
electron subbands

Treatment of on-site potential

- ◆ After achieving self-consistence including the Coulomb Tail, the device is subdivided at the point defect location:



- ◆ Calculation of the Green's functions of the surfaces S_1 and S_2 :

$$\langle l_1, m_1, n_1 | G_{S_1}(e) | l_1', m_1', n_1' \rangle = \sum_i \langle l_1, m_1, n_1 | ?_{n_1, i} \rangle \langle ?_{n_1, i} | G_i^1(e) | ?_{n_1', i} \rangle \langle ?_{n_1', i} | l_1', m_1', n_1' \rangle$$

$$\langle l_2, m_2, n_2 | G_{S_2}(e) | l_2', m_2', n_2' \rangle = \sum_i \langle l_2, m_2, n_2 | ?_{n_2, i} \rangle \langle ?_{n_2, i} | G_i^2(e) | ?_{n_2', i} \rangle \langle ?_{n_2', i} | l_2', m_2', n_2' \rangle$$

Treatment of on-site potential

- ◆ U_d is then included using the Dyson equation:

$$G'_{S2}(\mathbf{e}) = \left(I - G_{S2}(\mathbf{e})U \right)^{-1} G_{S2}(\mathbf{e})$$

▲ Intra-atomic potential matrix

- ◆ Retarded Green function of the uncoupled system:

$$G_S^0(\mathbf{e}) = \begin{bmatrix} G_{S1}(\mathbf{e}) & 0 \\ 0 & G'_{S2}(\mathbf{e}) \end{bmatrix}$$

- ◆ Calculation of the current*:

$$I = -\frac{4pe}{\hbar} \int_{-\infty}^{+\infty} d\mathbf{e} \text{Tr}_1 \left[N_{11}^0 \Lambda_{11}^+ V_{12} N_{22}^0 V_{21} \Lambda_{11} \right] (f_S(\mathbf{e}) - f_D(\mathbf{e}))$$

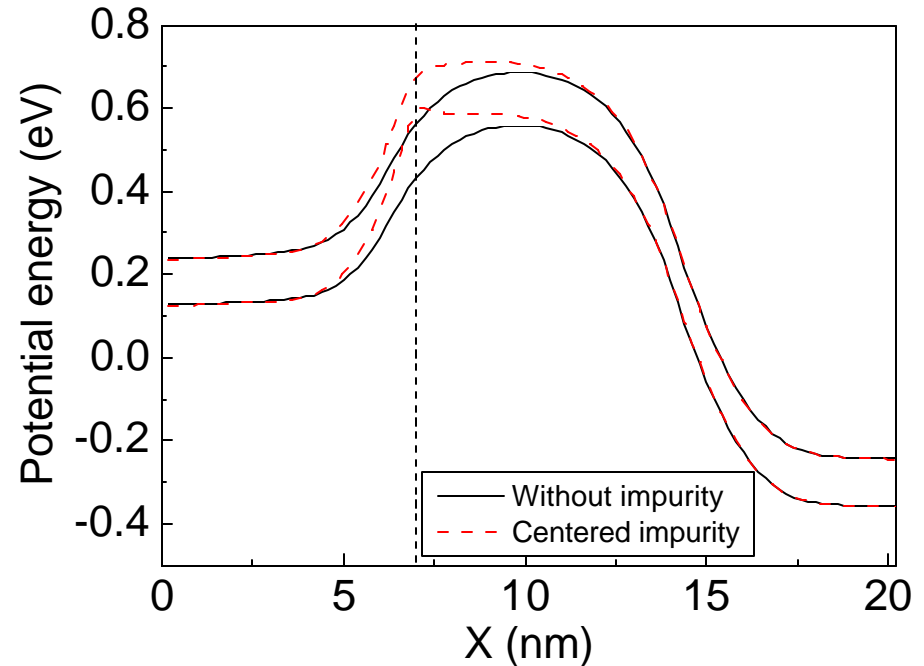
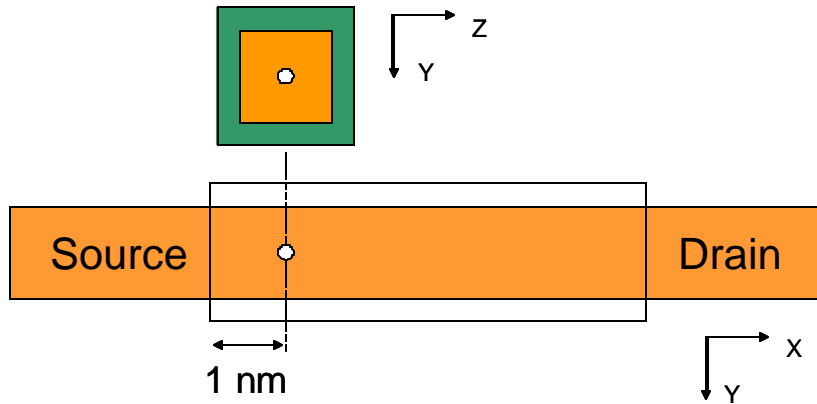
$$N^0 = \begin{bmatrix} -\frac{1}{p} \text{Im}(G_S^0) \\ p \end{bmatrix} \quad V = \begin{bmatrix} 0 & H_{12} \\ H_{21} & 0 \end{bmatrix} \quad \Lambda = \left[I - G_S^0 V G_S^0 V \right]^{-1}$$

Results

Influence of point defect

Simulation results

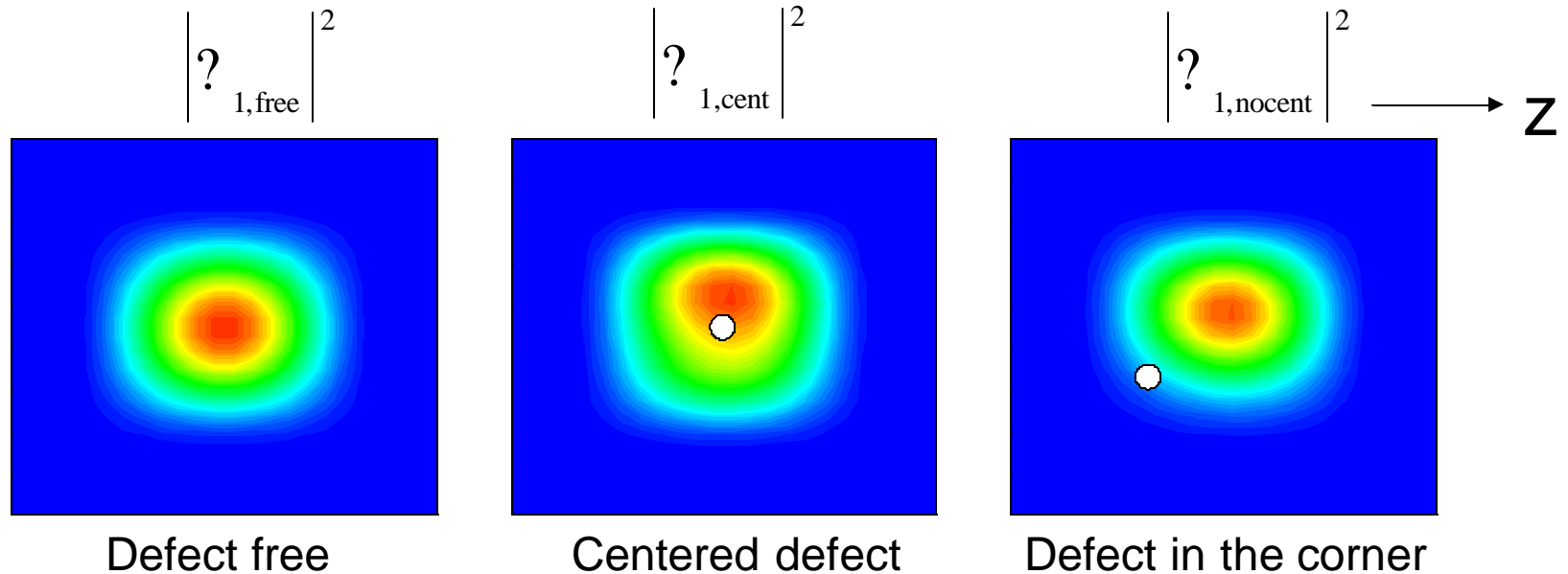
- ◆ Electronic subbands: Effect of the Coulombic potential (valley (010))



- ✓ Subband profile is affected by the impurity.
- ✓ Subbands are still independent: justification of the mode-space approach.
- ✓ Acceptor impurity increases the channel barrier.

Simulation results

- ◆ Evolution the 1st confinement eigenstate (valley (010)):

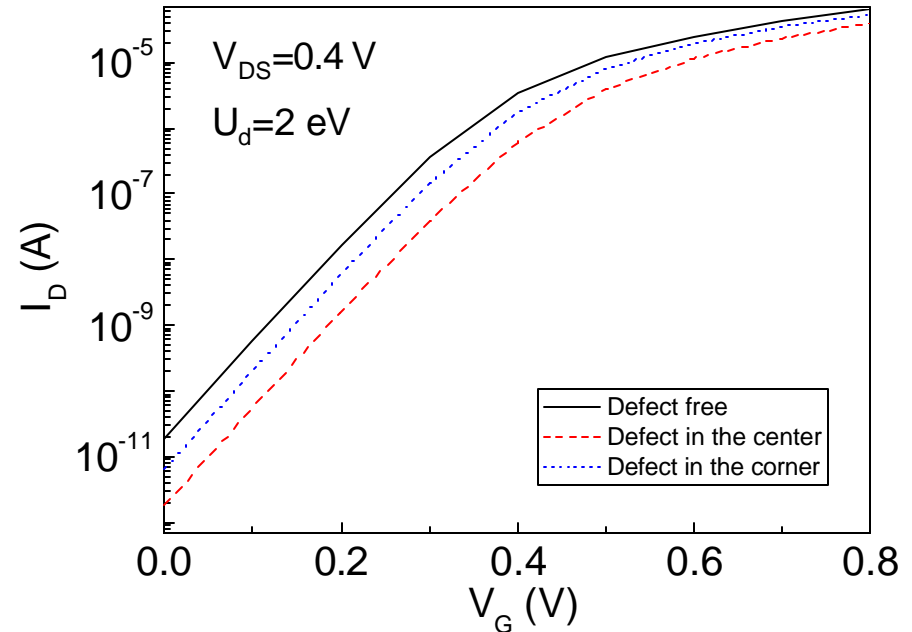
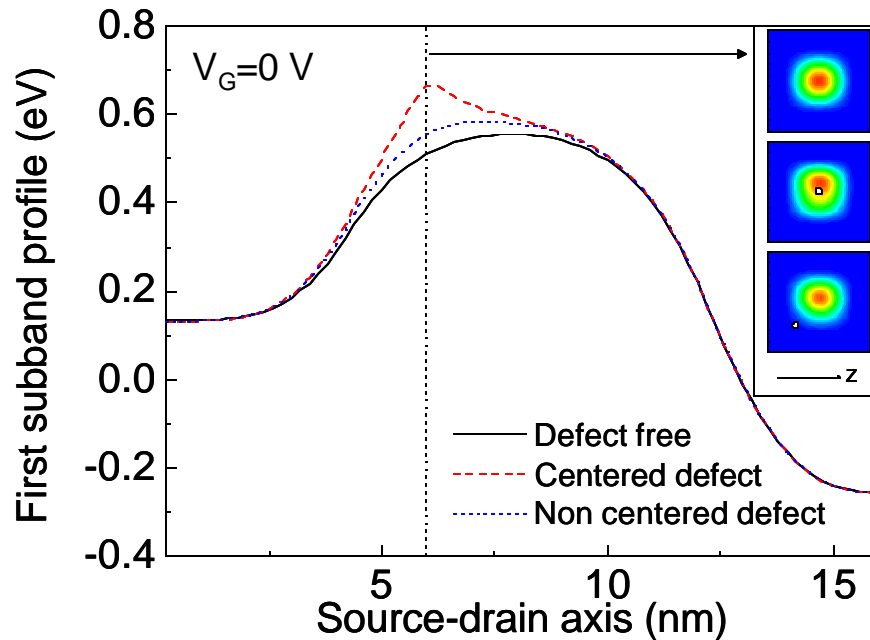


✓ Highest variations of the eigenstate with centered impurity.

✓ Scalar product $\left\langle ?_{1,\text{free}} \left| ?_{1,\text{cent}} \right. \right\rangle \sim 0.95$: weak variations.

Simulation results

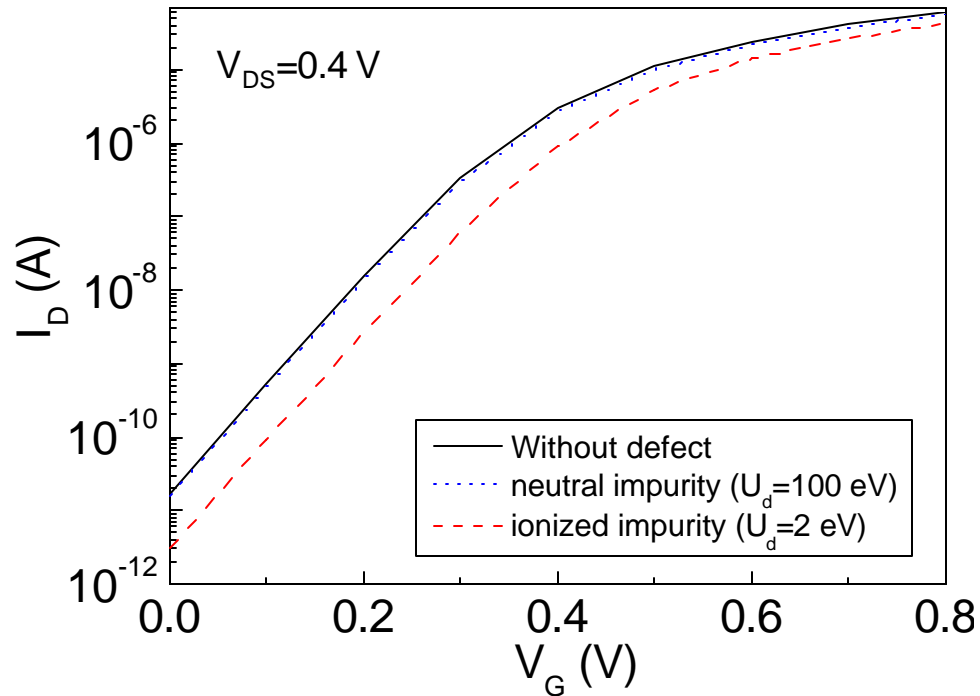
- ◆ First subband profile and current characteristics:



- ✓ Defect in the corner: weak influence on the subband profile.
- ✓ Defect free: highest current.
- ✓ Centered defect: lowest current.
- ✓ Defect in the corner: intermediate behavior: current decrease of 50%.
- ✓ Variation of the subthreshold slope.

Simulation results

- ◆ Influence of Coulomb potential:



- ✓ On-site potential defect does not affect the total current.
- ✓ Coulombic potential has the most significant impact.
- ✓ Electrons can be transmitted through the unperturbed neighboring atoms.

Conclusion

- ◆ Modeling of electron-ion interaction based on the NEGF formalism.
- ◆ Study of the effect the acceptor impurity in terms of physical properties.
- ◆ Centered impurity involves a significant degradation of the current.
- ◆ Not only a shift of the current but rather a subthreshold slope variation.
- ◆ The Coulomb potential has a prevalent rule compared to the on-site potential of the impurity.
- ◆ Treatment of donor impurities in source and drain.